

One-step of Sub-wavelength Patterning of Plasmonic Gratings in Metal-Polymer Composites

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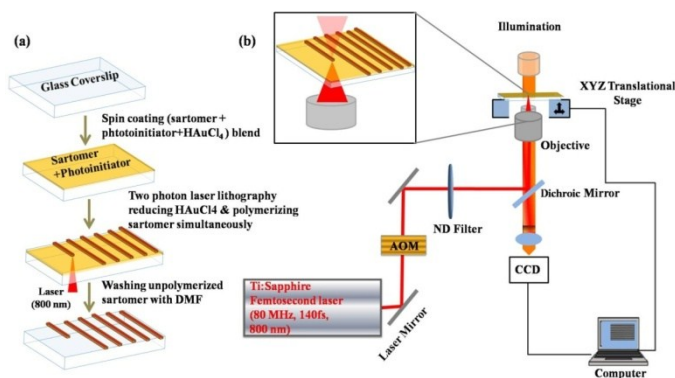


Fig.S1. Schematic of the fabrication process used for TPL of metallic structures inside polymer matrix

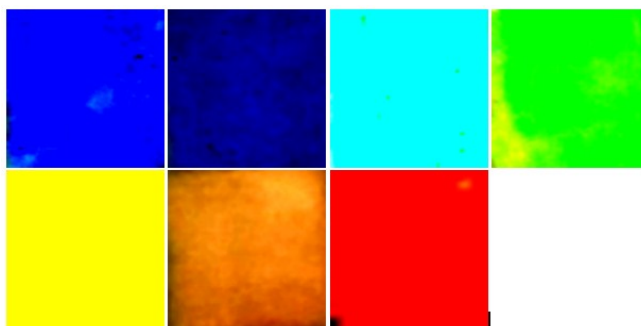


Fig S2. Optical images of the 5wt% gold loaded grating (840µm X 840µm) captured in reflection mode at different angles

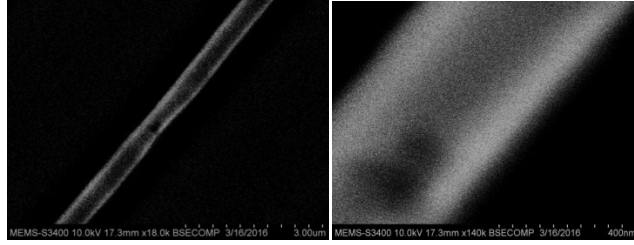


Fig. S3. Backscattered electron image of 5wt% gold loaded polymeric line confirming the presence of small gold nanoparticles

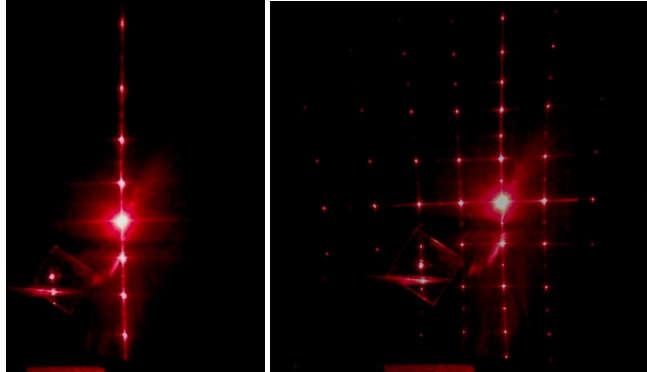


Fig. S4. Diffraction patterns obtained from 1D grating and 2D mesh structure respectively

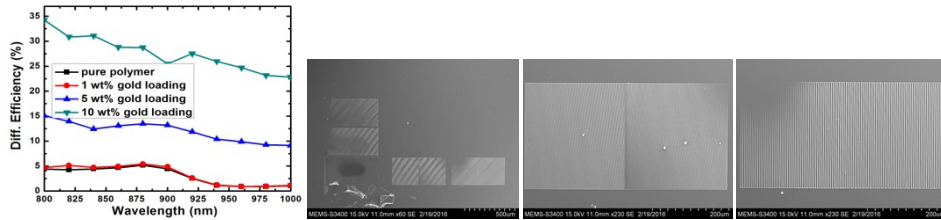


Fig. S5. Diffraction efficiency of first diffraction order (+1) and SEM images of $560 \times 280 \mu\text{m}^2$ gratings written in pure sartomer at different spacings

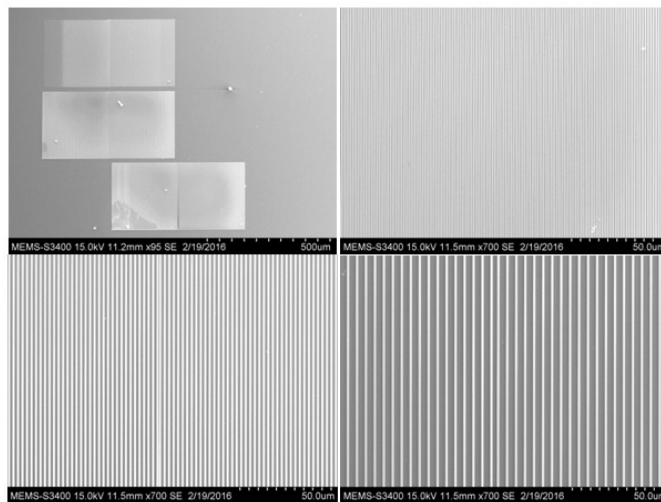


Fig. S6. SEM images of $560 \times 280 \mu\text{m}^2$ gratings written in 1wt% gold loaded sartomer at different spacings

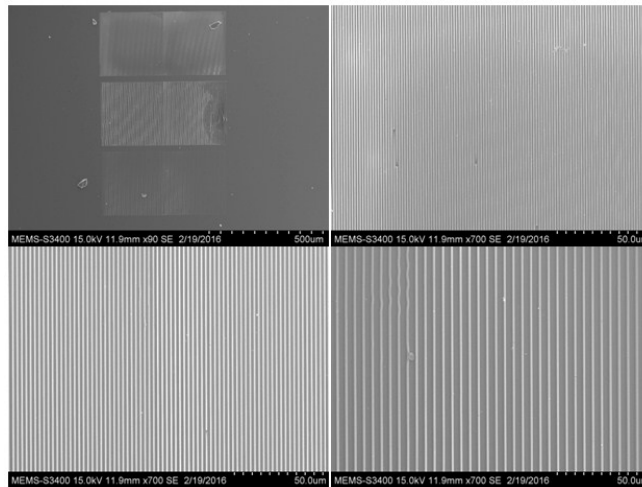


Fig S7. SEM images of $560 \times 280 \mu\text{m}^2$ gratings written in 5wt% gold loaded sartomer at different spacings

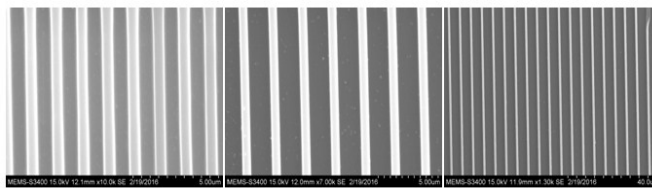


Fig. S8. Zoomed in SEM images of $560 \times 280 \mu\text{m}^2$ gratings written in 10wt% gold loaded sartomer at different spacings

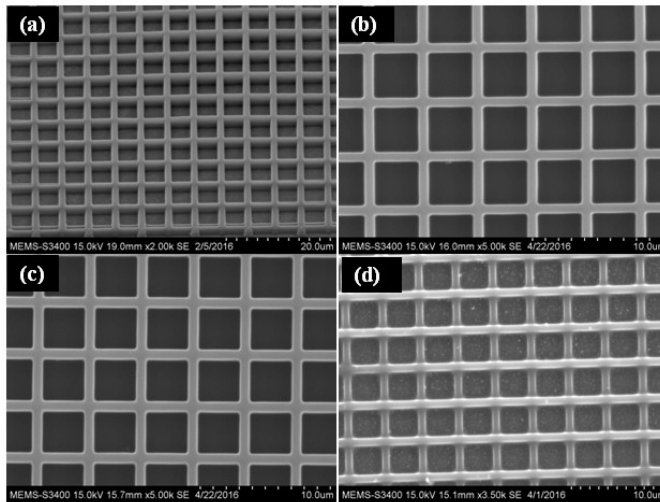


Fig. S9. Zoomed in SEM images of $560 \times 560 \mu\text{m}^2$ mesh structures written in 0wt%, 1wt%, 5wt% and 10wt% gold loaded sartomer respectively

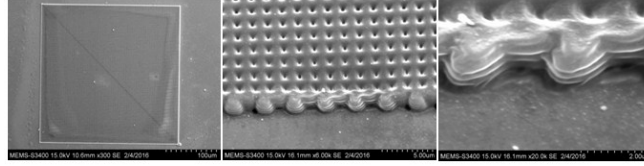


Fig. S10. SEM images of multilayered mesh structure at different magnifications